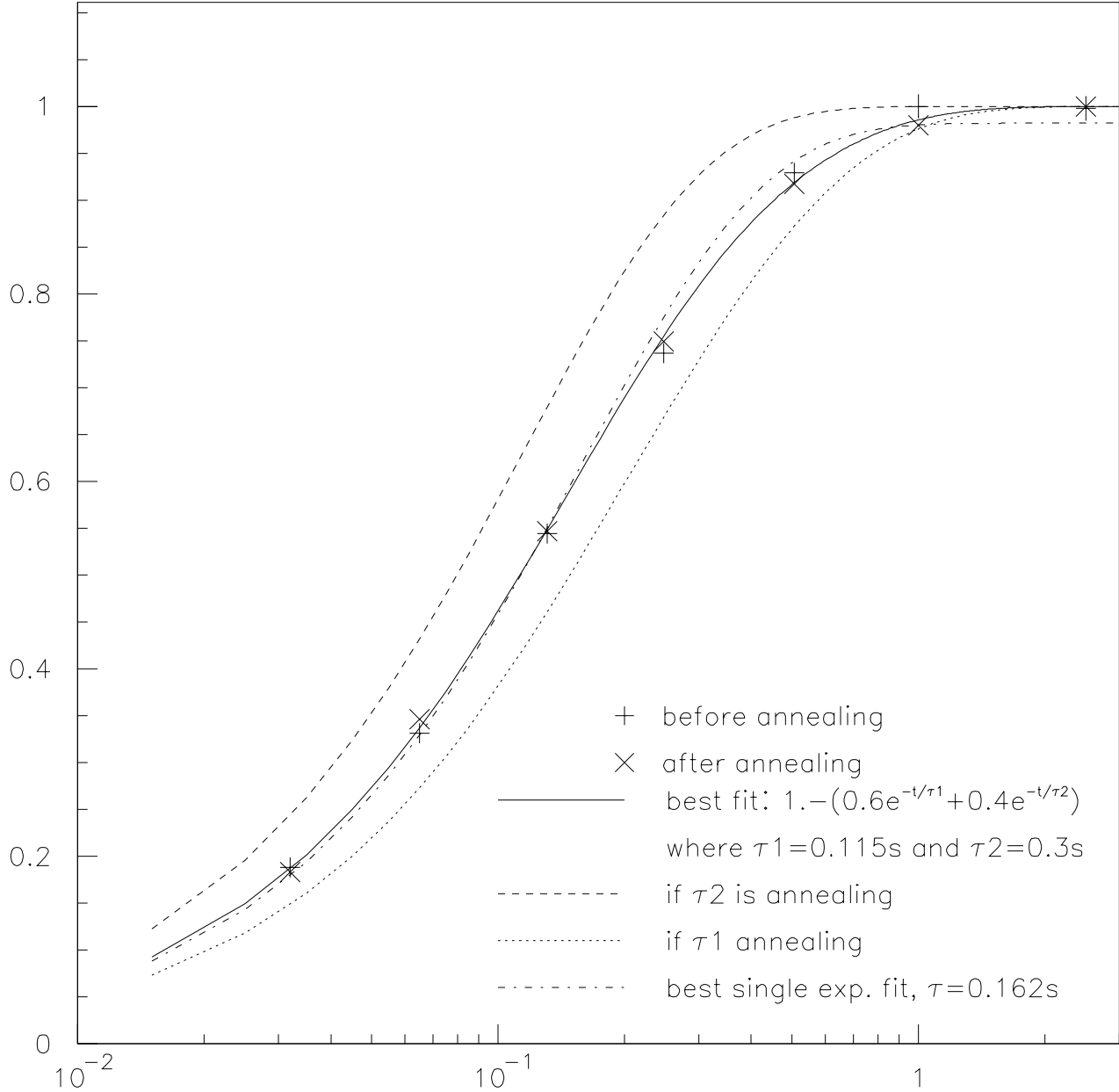


Comparison before – after annealing, T=202°K



Relative traps capacity vs. time since sweeping charge injection (sec)